

## **AMENDMENTS TO THE SPECIFICATION**

**Please amend the paragraph beginning at page 4, line 17 as follows:**

Further, the present invention relates to a process for the production of the above ceramic thin film coating material having a ~~slop~~ slope structure, which process comprises coating a base material surface with a modified organosilicon polymer having a structure obtained by modifying an organosilicon polymer with an organometallic compound or a mixture of an organosilicon polymer or said modified organosilicon polymer with an organometallic compound, carrying out a predetermined heat treatment, and calcining the resultant base material in an oxidizing atmosphere, an inert atmosphere or a nitrogen-containing atmosphere.